

Application Data Sheet**Application Information**

Application Type::	Regular
Subject Matter::	Utility
CD-ROM or CD-R:	None
Title::	PRODUCTION METHOD OF SYNTHETIC SILICA GLASS AND THERMAL TREATMENT APPARATUS
Attorney Docket Number::	109067.01
Suggested Drawing Figure::	
Total Drawing Sheets::	22
Small Entity::	No

Applicant Information

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Shouji
Middle Name::	
Family Name::	YAJIMA
Name Suffix::	
City of Residence::	Sagamihara-shi
State or Province of Residence::	Kanagawa-ken
Country of Residence::	Japan

Applicant Authority type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Hiroyuki
Middle Name::	

Family Name:: HIRAIWA
Name Suffix::
City of Residence:: Yokohama-shi
State or Province of Residence:: Kanagawa-ken
Country of Residence:: Japan

Applicant Authority type:: Inventor
Primary Citizenship Country:: Japan
Status:: Full Capacity
Given Name:: Yasuji
Middle Name::
Family Name:: ISHIDA
Name Suffix::
City of Residence:: Tuki-gun
State or Province of Residence:: Kanagawa-ken
Country of Residence:: Japan

Correspondence Information

Correspondence Customer Number:: 25944

Domestic Priority Information			
Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This Application is a	Division of	09/806,236	03/28/01
Which is a	National Stage of	PCT/JP00/05412	08/11/00
Foreign Priority Information			
Country::	Application Number::	Filing Date::	Priority Claimed::
Japan	P1999-228197	08/12/99	Yes

Assignee Information	
Assignee Name::	NIKON CORPORATION
Street of mailing address::	2-3 Marunouchi 3-chome
	Chiyoda-ku, Tokyo 100-8331 Japan
City of mailing address::	
State or Province of mailing address::	
Country of mailing address::	Japan
Postal or Zip Code of mailing address::	100-8331